## IN THE SPECIFICATION:

Please replace the paragraph beginning at page 9 line 8, with the following rewritten paragraph:

A thin protective layer 73 may be laid on the paint or other responsive surface [[is]] if desired.

Please replace the paragraph beginning at page 12 line 2, with the following rewritten paragraph:

The thin film silicon carbide Peltier effect layer can best be fabricated by plasma arc deposition essentially the same as that described in Snaper U.S. Patent No. 5,254,235 which is made [[in]] a part hereof by reference for its disclosure of this technique. The apparatus and method outlined therein would be identical. Only the deposition materials would differ. Other suitable fabrication methods would include chemical vapor disposition, sputtering, and vacuum deposition.

Please replace the paragraph beginning at page 13 line 6, with the following rewritten paragraph:

Another unique feature possible is that by controlling the temperature of the thermochromic film containing the radar shielding particles, the particles can be made to expand or contract by controlling the over all film temperature. This minute expansion, and/or contraction with temperature [charge] change can effectively lengthen or shorten the dipole particles and thus can be "tuned" for a specific impinging signal. The

size change of the temperature controlled particles in most case need only be very minute, perhaps on the order of nanometers, to achieve this effect.